

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Ritsuko KAWASAKI et al.
Serial No. 09/651,889
Filed: August 30, 2000
For: SEMICONDUCTOR DEVICE,
MANUFACTURING METHOD
THEREOF AND ELECTRONIC
DEVICE



) Group Art Unit: 2814
) Examiner: D. Farahani
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AMENDMENT

Commissioner of Patents
Washington, D.C. 20231

Dear Sir:

In response to the Examiner's non-final Office Action dated June 6, 2002, please amend the above-identified application as follows.

IN THE CLAIMS:

Please amend claims 1-3 and 11-16 as follows. The amendments to the claims are outlined in an Attachment to the Amendment using the conventional indication method of bracketing and underlining.

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1. (Twice Amended) A semiconductor device comprising a TFT containing an active layer having a channel forming region,
wherein the channel forming region has a convex portion or a concave portion extending in a channel width direction.

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